



Future Normal in Semiconductor

2025-02-14(금), 09:00-10:45

좌장: 추후업데이트 예정

G. Device & Process Modeling, Simulation and Reliability 분과

[FK1-G] Reliability & Packaging Simulation

<p>FK1-G-1 09:00-09:15</p>	<p>Insertion of Protective Layer for Enhancing Effect of N₂O Plasma Treatment on NBS Stability in IGZO TFTs Seungyoon Shin, Jinkyu Lee, Hyunjin Choi, Seong-In Cho, and Soo-Yeon Lee Department of Electrical and Computer Engineering, Inter-university Semiconductor Research Center, Seoul National University</p>
<p>FK1-G-2 09:15-09:30</p>	<p>Degradation modeling of positive bias stress reliability in a-IGZO TFTs considering the effects of oxygen and hydrogen Do Hun Kim¹, Seung Joo Myoung¹, Dong Hyeop Shin¹, Jung Rae Cho¹, Donguk Kim¹, Changwook Kim¹, Dae Hwan Kim¹, Narae Han², Jee-Eun Yang², Younjin Jang², and Sangwook Kim² ¹School of Electrical Engineering, Kookmin University, ²Samsung Advanced Institute of Technology, Samsung Electronics</p>
<p>FK1-G-3 09:30-09:45</p>	<p>Comprehensive Analysis of Proton Collision Effects in SOI MOSFETs using Transient and Steady-State Responses Hwan Jin Kim¹, Haesung Kim¹, Hyojin Yang¹, Yubin Choi¹, Sujong Kim¹, Hyunwook Jeong¹, Sung-Jin Choi¹, Dae Hwan Kim¹, Dong Myong Kim², Sung Yun Woo³, and Jong-Ho Bae¹ ¹School of the Electronic Engineering, Kookmin University, ²Department of Advanced Technology, DGIST, ³School of Electronic and Electrical Engineering, Kyungpook National University</p>
<p>FK1-G-4 09:45-10:00</p>	<p>Uncovering Novel Time Exponent Variations in PBTl of a-IGZO Transistors via a 1 μs Ultrafast On-the-Fly Technique Taewon Seo¹, Changeon Jin¹, and Yoonyoung Chung^{1,2,3} ¹Department of Electrical Engineering, POSTECH, ²Department of Semiconductor Engineering, POSTECH, ³Center for Semiconductor Technology Convergence, POSTECH</p>
<p>FK1-G-5 10:00-10:15</p>	<p>Analysis of Proton-Induced Electrical Degradation in a-IGZO TFTs under Aerospace Environments Yubin Choi¹, Haesung Kim¹, Hyojin Yang¹, Junseong Park¹, Hyunwook Jeong¹, Sujong Kim¹, Hwan Jin Kim¹, Sung-Jin Choi¹, Dae Hwan Kim¹, Dong Myong</p>



제 32회 한국반도체학술대회

The 32nd Korean Conference on Semiconductors

2025년 2월 12일(수)-14일(금) | 강원도 하이원리조트

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	Kim ² , Sung Yun Woo ³ , and Jong-Ho Bae ¹ ¹ School of the Electronic Engineering, Kookmin University, ² Department of Advanced Technology, DGIST, ³ School of Electronic and Electrical Engineering, Kyungpook National University
FK1-G-6 10:15-10:30	Data-driven Method for Predicting Thermo-mechanical Property Maps of Patterned Semiconductor Packages Using Machine Learning Jeong-Hyeon Park, Sung Jun Kang, and Eun-Ho Lee Sungkyunkwan University
FK1-G-7 10:30-10:45	Development of an In-House Finite Element Method Simulator for Static Structural Analysis of a Warped Wafer Sung-Min Hong School of Electrical Engineering and Computer Science, GIST